	Hits	Search Text	DBs
41	33	((system or apparatus or module) same (expos$4 or irradiat$4 or illuminat$4) same (first or initial) same (alignment or interferometer)) and ((second or double or multiple or subsequent$4 or sequent$4) same (direct or maskless or blank$2) same (expos$4 or illuminat$4 or irradiat$4) same (apparatus or system or module)) and ((diffract$4 or holographic or interference or (dual$4 near6 beam)) same (expos$4 or illuminat$4 or pattern)) and (line$3width or lines or (line near9 space)) and laser and (align$6 same pattern same (post$4exposure or post$5develop$4 or (second near5 (ilulminat$4 or irradiat$4 or expos$4))))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

| 42 | 39 | ((system or apparatus or module) same (expos$4 or irradiat$4 or illuminat$4) same (first or initial) same (alignment or interferometer)) and ((second or double or multiple or subsequent$4 or sequent$4) same (direct or maskless or blank$2) same (expos$4 or illuminat$4 or irradiat$4) same (apparatus or system or module)) and ((diffract$4 or holographic or interference or (dual$4 near6 beam)) same (expos$4 or illuminat$4 or pattern)) and laser and (align$6 same pattern same (post$4exposure or post$5develop$4 or (second near5 (iluminat$4 or irradiat$4 or expos$4)))) | US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB |

	Hits	Search Text	DBs
43	48	((system or apparatus or module) same (expos$4 or irradiat$4 or illuminat$4) same (first or initial) same (alignment or interferometer)) and ((second or double or multiple or subsequent$4 or sequent$4) same (direct or maskless or blank$2) same (expos$4 or illuminat$4 or irradiat$4) same (apparatus or system or module)) and ((diffract$4 or holographic or interference or (dual$4 near6 beam)) same (expos$4 or illuminat$4 or pattern)) and laser and (align$6 same pattern same (post$4exposure or post$5develop$4 or (second near5 (illuminat$4 or irradiat$4 or expos$4))))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB